

United States Patent [19]

Wang et al.

[54] MATERIALS AND METHODS FOR ETCHING SILICIDES, POLYCRYSTALLINE SILICON AND POLYCIDES

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- [73] Assignce: Applied Materials, Inc., Santa Clara, Calif.
- [21] Appl. No.: 778,326
- [22] Filed: Oct. 17, 1991

Related U.S. Application Data

- [60] Division of Ser. No. 443,811, Nov. 29, 1989, Pat. No. 5,112,435, which is a continuation of Ser. No. 185,256, Apr. 19, 1988, abandoned, which is a continuation of Ser. No. 786,783, Oct. 11, 1985, abandoned.
- [51]
 Int. Cl.⁵
 H01L 21/302
 H01L 21/302
- 156/646; 156/656; 156/657; 156/662 [58] Field of Search 156/643, 646, 656, 657,
- 156/662; 252/79.3

[11] Patent Number: 5,219,485

[45] Date of Patent: Jun. 15, 1993

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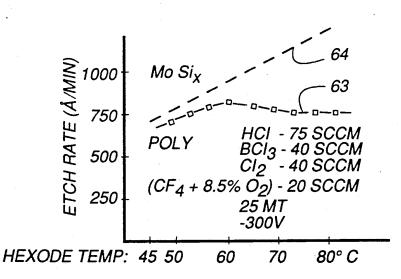
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Primary Examiner—Thi Dang Attorney, Agent, or Firm—Philip A. Dalton

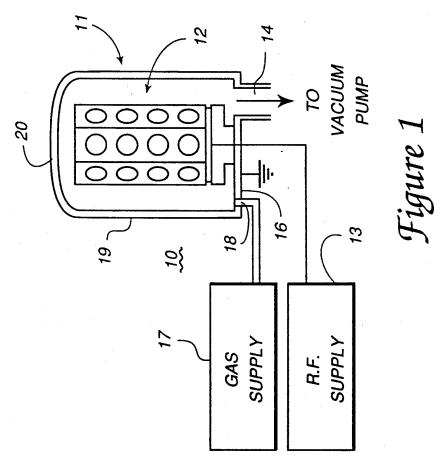
[57] ABSTRACT

Gas chemistry and a related RIE mode process is described for etching silicides of the refractory metals titanium, tantalum, tungsten and aluminum and for etching composites of these silicides on polycrystalline silicon layers. BCl₃ is added to the HCl/Cl₂ gas chemistry used for the polysilicon etch along with additives selected from fluorinated gases and oxygen to satisfy the multiple requirement of the two-step silicide-polysilicon etch process, including the silicide-to-polysilicon etch ratio requirement.

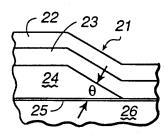
9 Claims, 11 Drawing Sheets

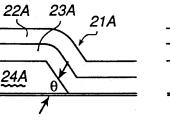


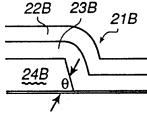
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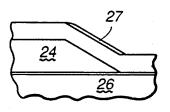


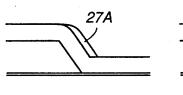


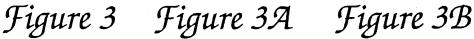




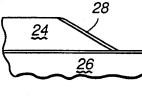
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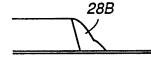


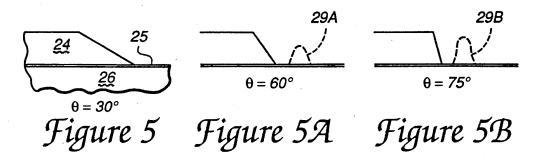




28A

Figure 4 Figure 4A Figure 4B





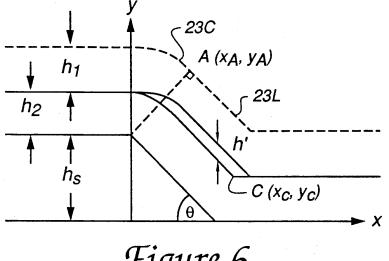
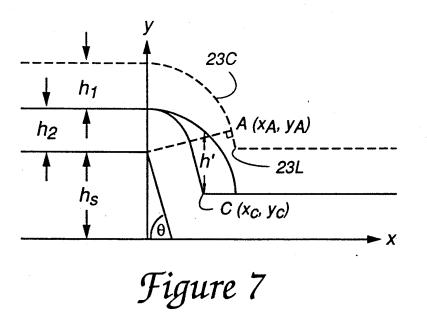
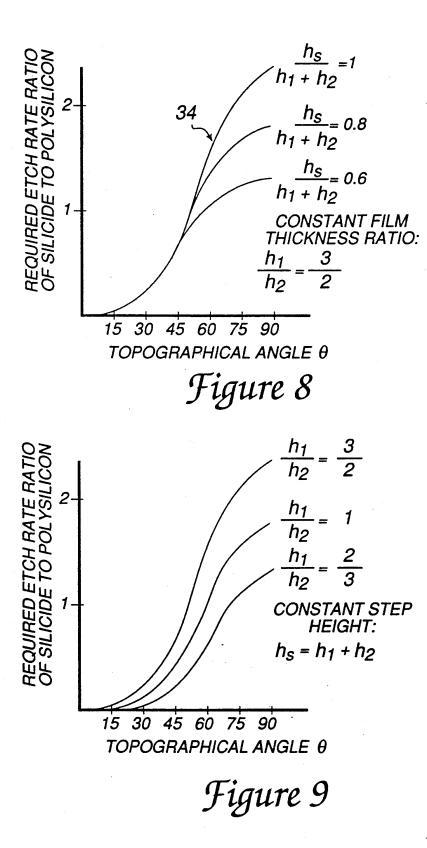


Figure 6



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